TOF MC Status

Qi Yan

PhD student of Institute of High Energy Physics, CAS

Old TOF MC Status Review

1: TOF simulation program is mainly written by E.Choumilov

2: Optical photon transmission simulated in scintillator+LG+PMT is simulated by LTRANS, a Fortran package

3: Using parameterized table to do simulation, namely time and charge simulation

Need to be better

- 1: finite geometry of LTRANS
- 2: Not flexible to do modification
- 3: Not be able to do online simulation
- 4: PMT parameters need to be update

Outline of new TOF Geant4 software

- 1: Geant4 optical photon simulation
- 2: TOF Geant4 Introduction
- 3: new PMT +electronic simulation
- 4: MC software development status
- 5:Tuning work
- 5: To do list

Geant4 optical photon simulation

100

80

1: Geometry volume

Box, Bend, Twist, Polygon....

2: Scintillation process simulation:

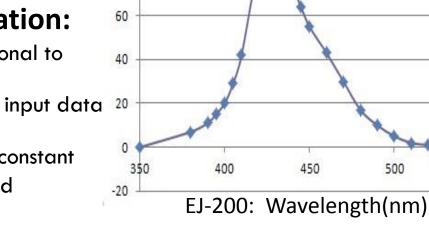
Number of photon generate proportional to energy lost during step

Yield, emission spectrum sample from input data

Emission time spectrum of rise and delay(fast/slow) with exponentail time constant

Birk saturation constant can be added

```
TOFSc Mt = new G4MaterialPropertiesTable();
TOFSc Mt->AddProperty("FASTCOMPONENT", PhEnergyS, Sci Fast, ENUMS);
TOFSc Mt->AddProperty("SLOWCOMPONENT", PhEnergyS, Sci Fast, ENUMS);// s
TOFSc Mt->AddProperty("RINDEX",
                                        PhEnergySI, Sci RIND, ENUMSI);
TOFSc Mt->AddProperty("ABSLENGTH",
                                        PhEnergySI, Sci ABSL, ENUMSI);
G4double DEDX=QEMAX*10000./MeV;
/ G4double DEDX=10000./MeV;
TOFSc Mt->AddConstProperty("SCINTILLATIONYIELD", DEDX);
TOFSc Mt->AddConstProperty("RESOLUTIONSCALE", 1.0);
TOFSc Mt->AddConstProperty("FASTTIMECONSTANT", 2.1*ns);
TOFSc Mt->AddConstProperty("SLOWTIMECONSTANT",2.1*ns);
TOFSc Mt->AddConstProperty("FASTSCINTILLATIONRISETIME",0.9*ns);
TOFSc Mt->AddConstProperty("SLOWSCINTILLATIONRISETIME",0.9*ns);
//TOFSc Mt->AddConstProperty("YIELDRATIO",0.8);
TOFSc Mt->AddConstProperty("YIELDRATIO",0.0);
TOFSc M->SetMaterialPropertiesTable(TOFSc Mt);
```



3: photon transmission in medium

The optical property of material medium can be define as a function of photon energy

photon absorption and propagation in medium according to the Material table

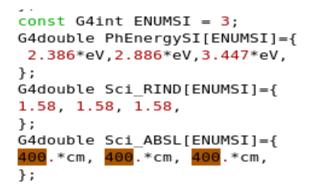
Wavelength shifting(WLS)+ Rayleigh scattering + Mie scattering is optional

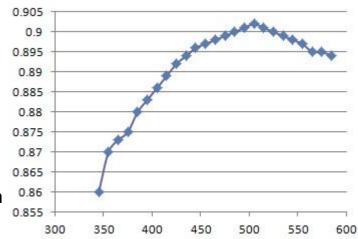
4: Boundary process

Dielectric-Dielectric: total internal reflection , Fresnel refraction, Fresnel reflection

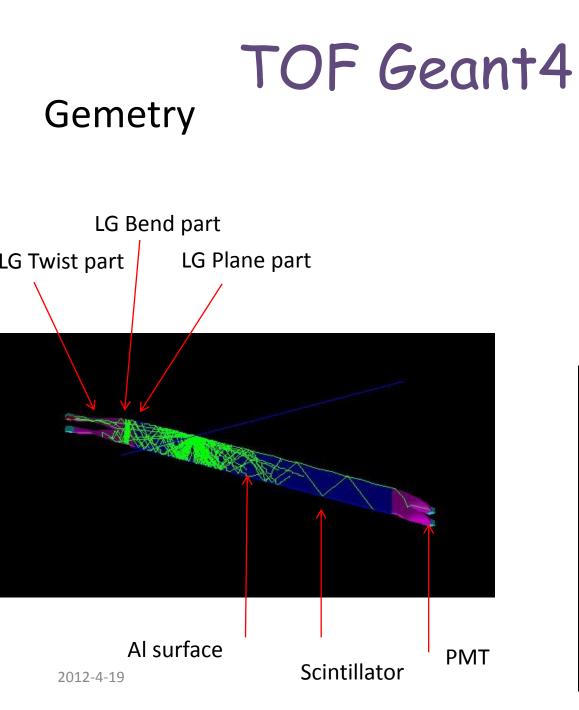
Dielectric-Metal: absorption, reflection, diffuse reflection

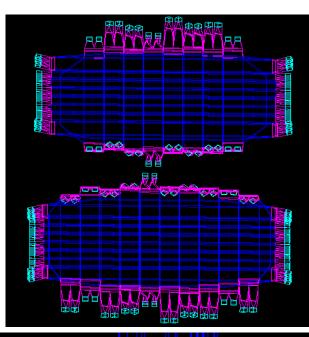
Volume bounary with the concept of Surface , allows for different feature depending on photon direction and photon energy

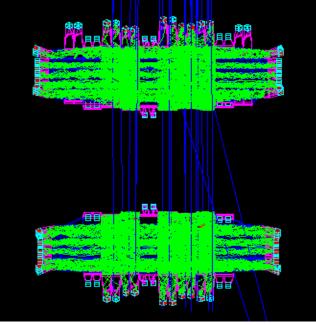




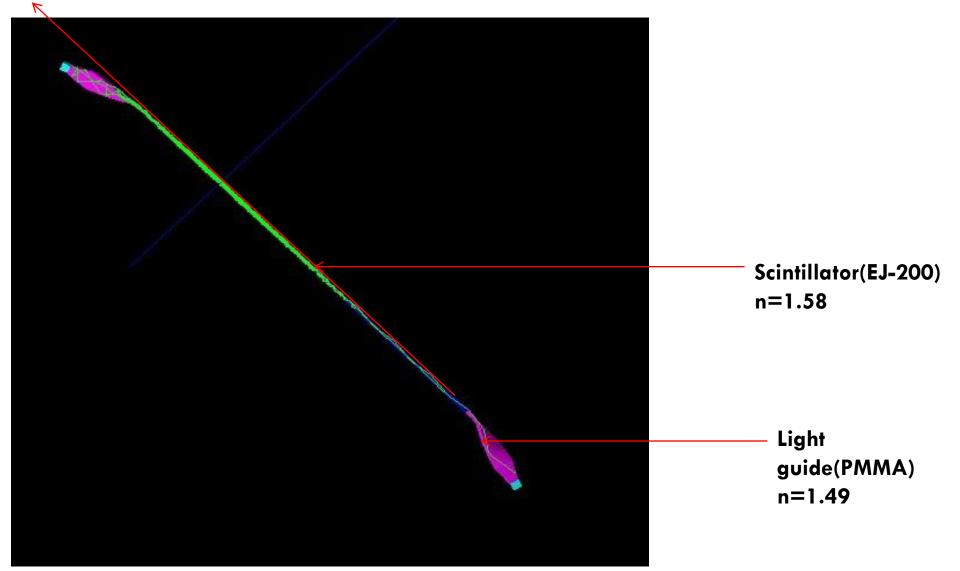
Al mylar reflection: Wavelength(nm)





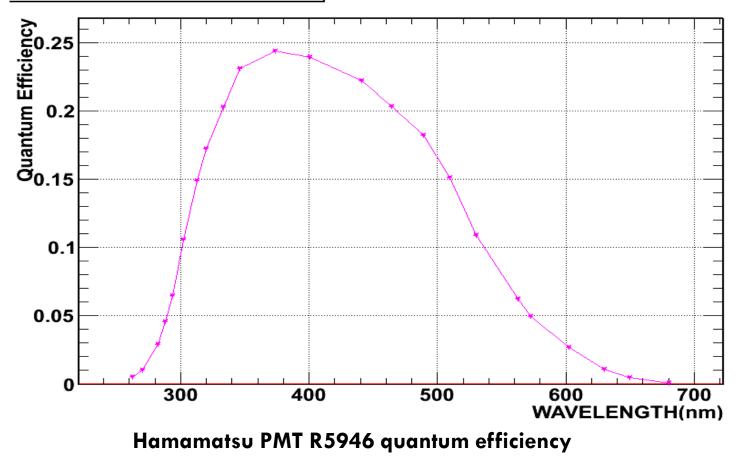


Al Skin: Vacuum gap (n=1)+Al wrap

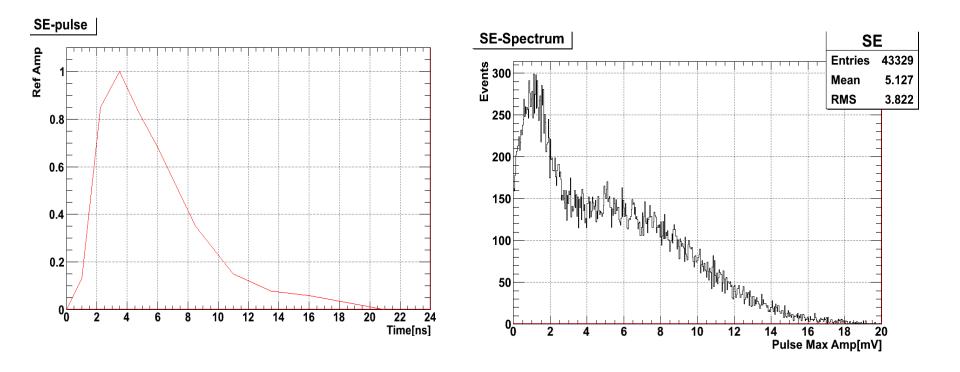


PMT Quantum efficiency simulation

PMT Quantum Efficiency



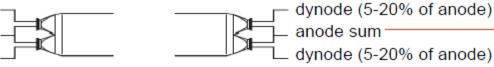
Single electron pulse + spectrum



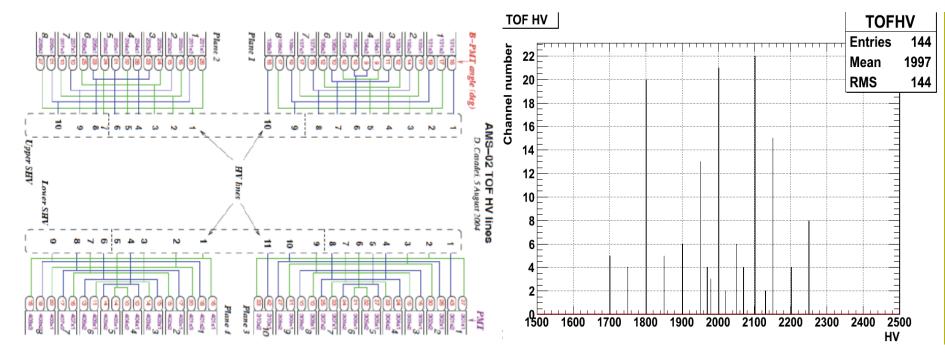
SE Pulse shape:

SE spectrum

Unbalance of HV for same side PMTs



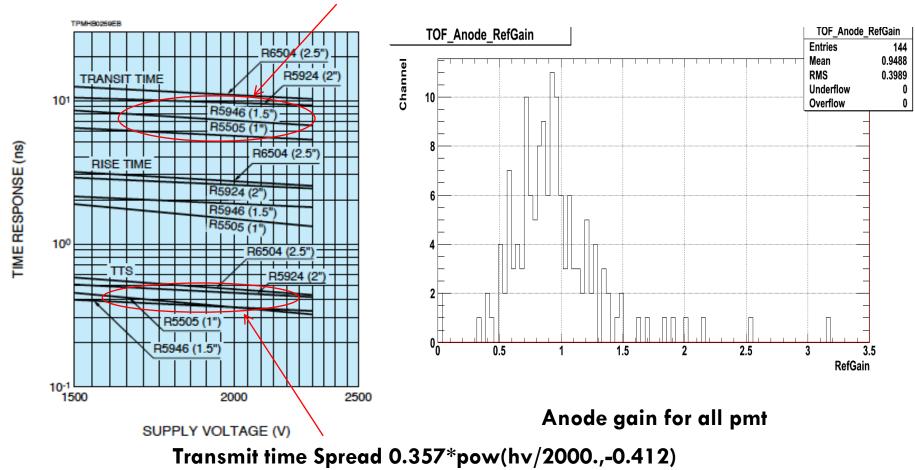
- Each counter must be able to operate with only one PMT powered in each side.



PMT HV Setting

PMT Transmit Time +Gain Unbalance

FIg.3: Typical Time Response Transmit Time=7.16 pow(hv/2000.,-0.567);



TOF Geant4 new source and update code for AMSsoft

New geant4 simulation code and connect to AMSsoft: TofSimUtil.h TofSimUtil.C g4tof.h g4tof.C New PMT and electronic simulation code: Tofsim02.h Tofsim02.C Tofdbc.h Tofdbc.C Update file:

geant4.h gvolume.h linkdef.h mccluster.h ntuple.h root.h commom.h

geant.C geant4.C g4physics.C gmat.C amsgeom.C gvolume.h mcluster.C event.C root.C job.C

2:New class

TOFMCPmtHitR: record each detect photon's information for further analysis: arriving PMT time, transmit time , energy, ...

3: New Database file

TofGainPMag_v1.dat : TOF PMT Anode and Dynode Gain + HV setting+LT HT SHT setting TofGeant4_v1.dat: using for tuning of Geant4 TOF

4:How to use newest Gean4 TOF simulation (icc/gcc))

1: TOF new PMT+ new electronic simulation

setenv TOFNEWSIM 1 (before compile): Tofsim02.C instead of tofsim02.C

2: Datacard: TOF new Geant4 online simulation

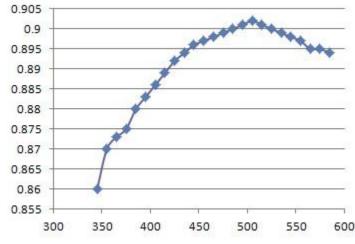
G4FFKEY.TFNewGeant4=1 MISCFFKEY.G4On=1

If you unsetenv TOFNEWSIM before compile, and switch off TFNewGeant4, old parameterize table and old simulation will be used without affect present simulation

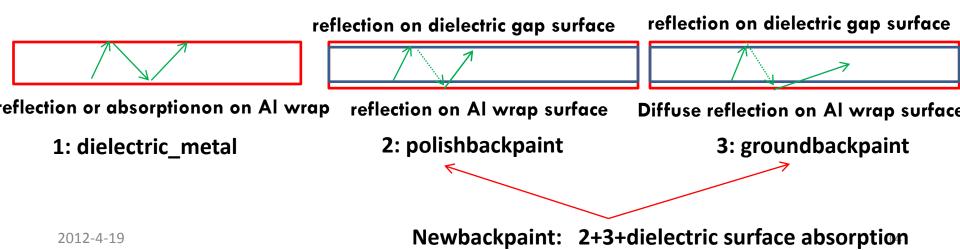
Tuning work in progress

Test Three Finish Model of LG+SC surface

- 1: dielectric_metal
- 2: polishbackpaint
- 3: groundbackpaint
- 4: newbackpaint(based on 2+3)

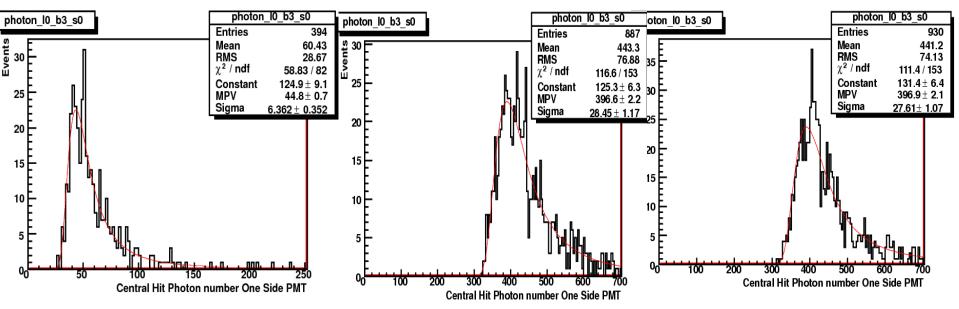


Al mylar reflection: Wavelength(nm)



Proton Photon Electron Number Comparison

Typical Bar one side Photon Number in Geant4 simulation

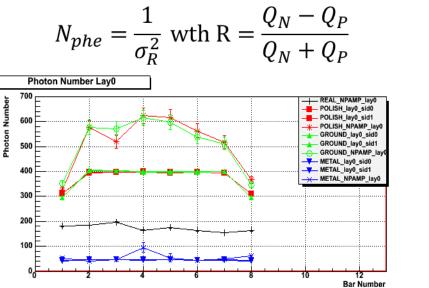


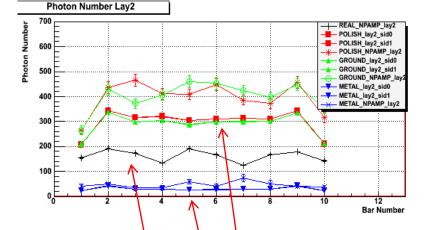
1: dielectric_metal

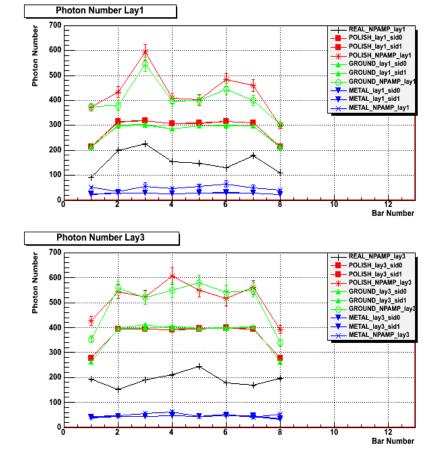
2: polishbackpaint

3: groundbackpaint

MC +ISS Proton Photon Electron



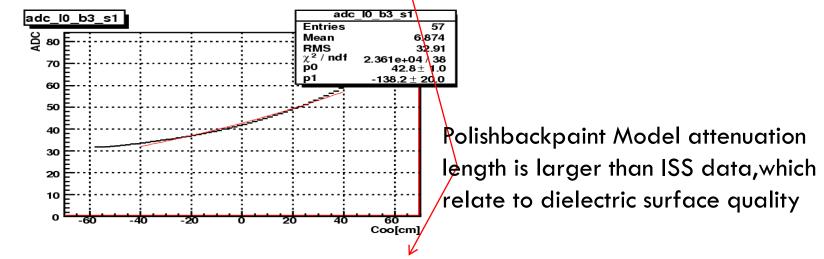




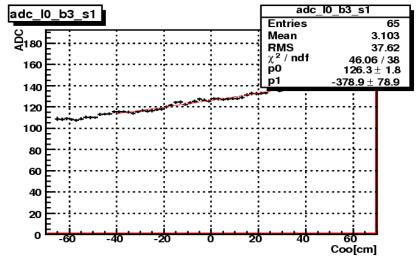
ISS photon number is about 200 for central region dielectric_metal Finish --photon number is 50 much lower(Model Abandon) Gap Model--photon number is 300 much higher but can used for further tuning

Amplitude Attenuation

ISS Typical Attenuation length is about 150cm



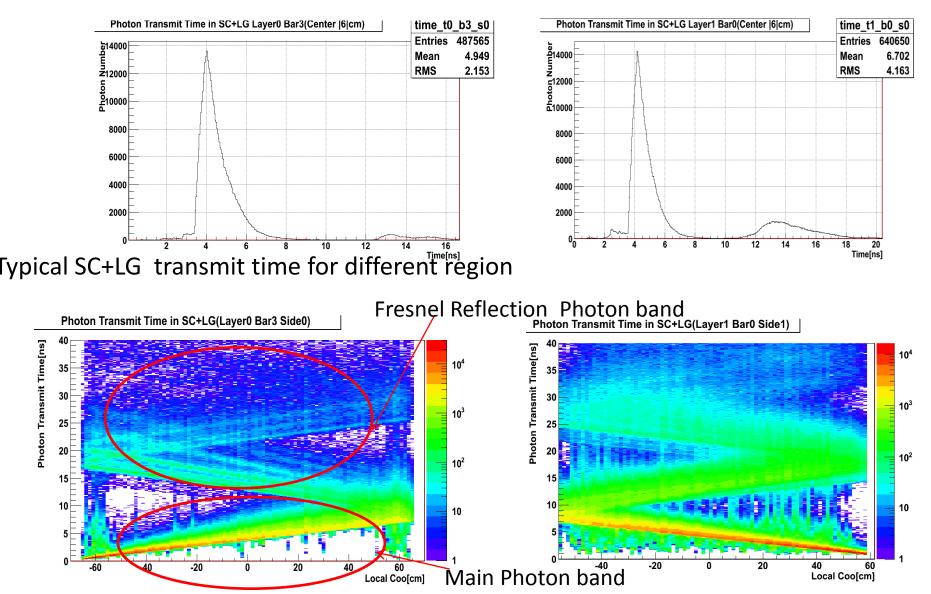
Polishbackpaint Model MC Typical Attenuation length is about 350cm



LG+SC dielectric surface absorption parameter need to adjust

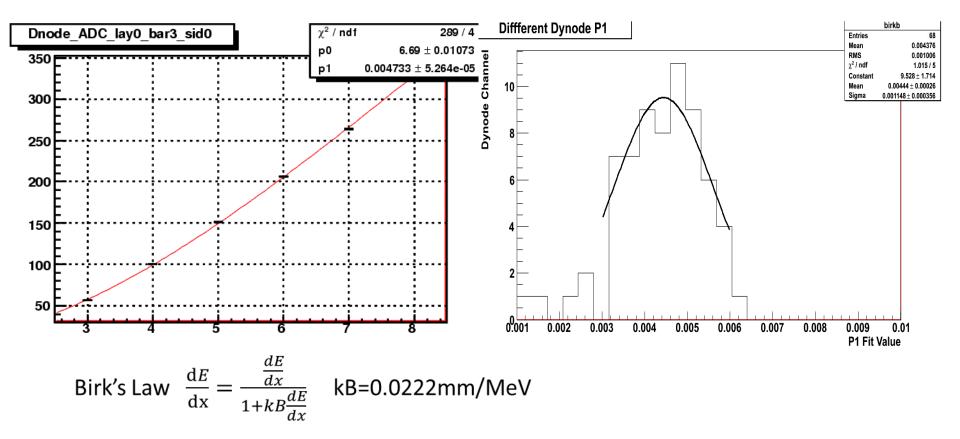
Photon Transmit Time in SC+LG

Typical SC+LG transmit time in Central region

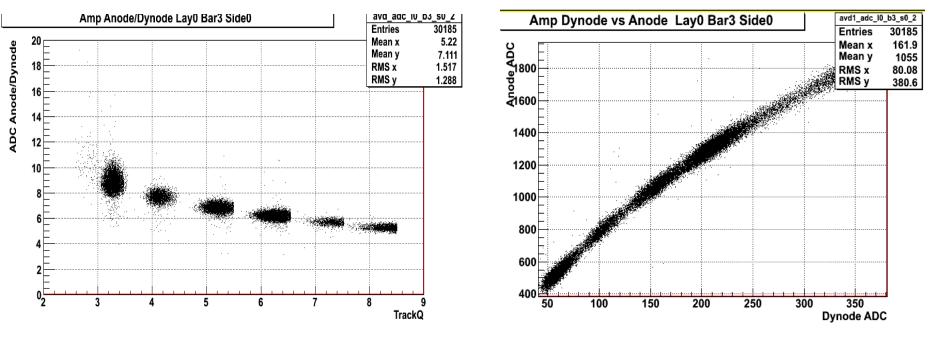


Birk's law for light yield saturation

 $Q = P0Z^2/(1 + P1Z^2)$



Anode Saturation

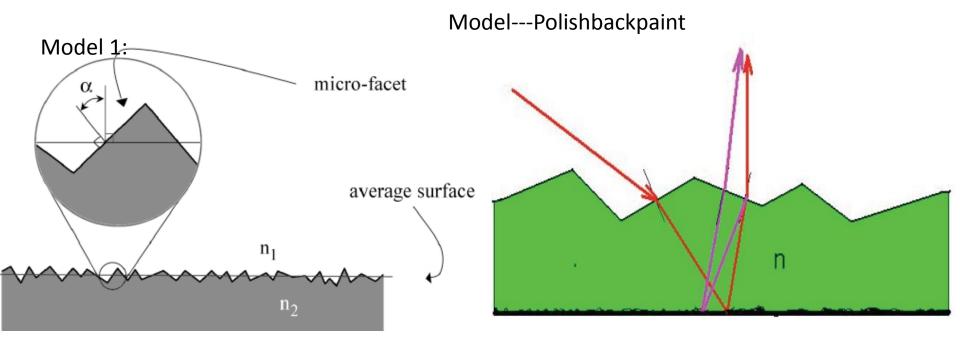


Need to do

Photon Electron number tuning

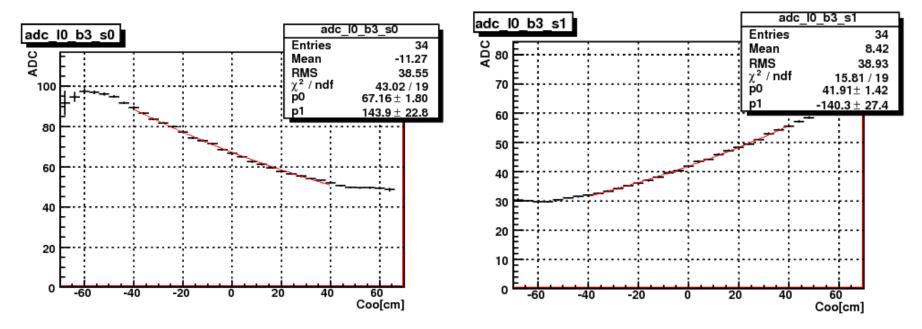
Relate to photon electron number loss:

- 1: dielectric surface-> sensitive to attenuation length
- 2: LG and Scintillator glue->sensitive to global photon efficiency



Tuning Surface According to attenuation length

Polishbackpaint Alpha=7.0deg



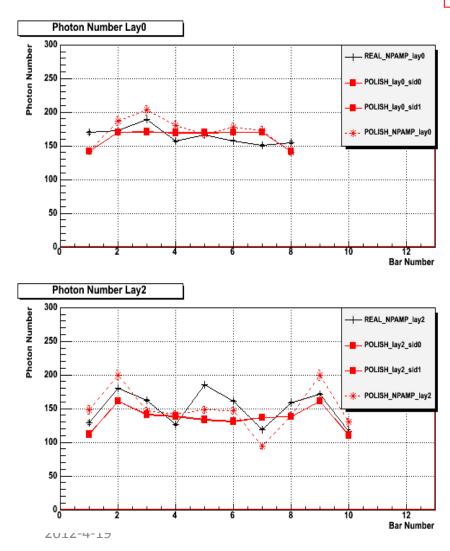
Tuning Surface the same attenuation length as real data

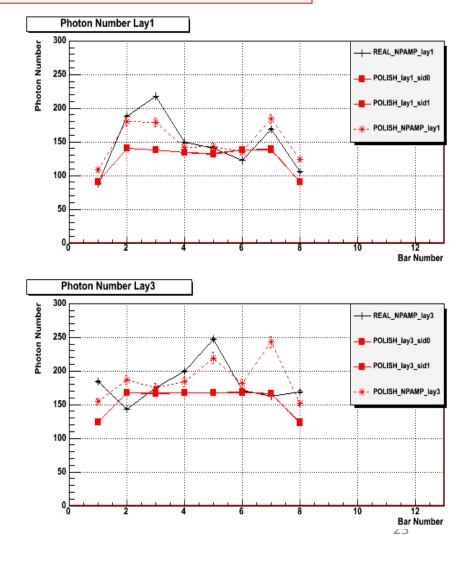
Then Tunning Proton Photon Number

 $N_{phe} = \frac{1}{\sigma_R^2}$ wth R = $\frac{\overline{Q}_N - Q_P}{Q_N + Q_P}$

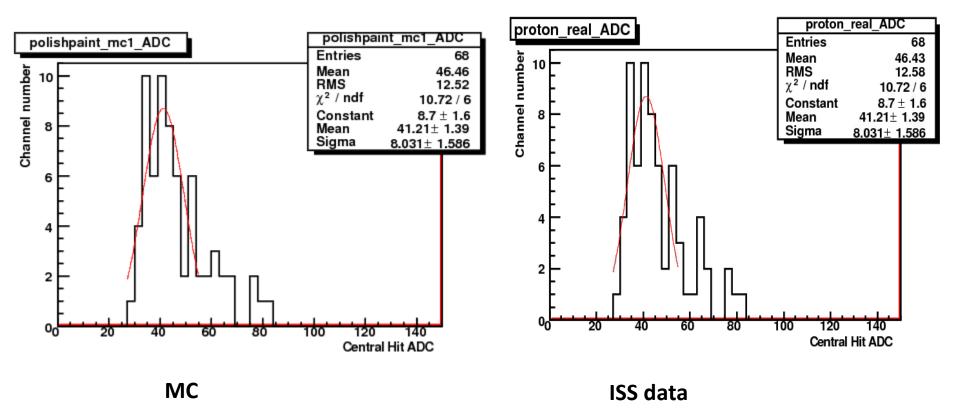
Black Photon number NP ISS

Red Photon number NP MC





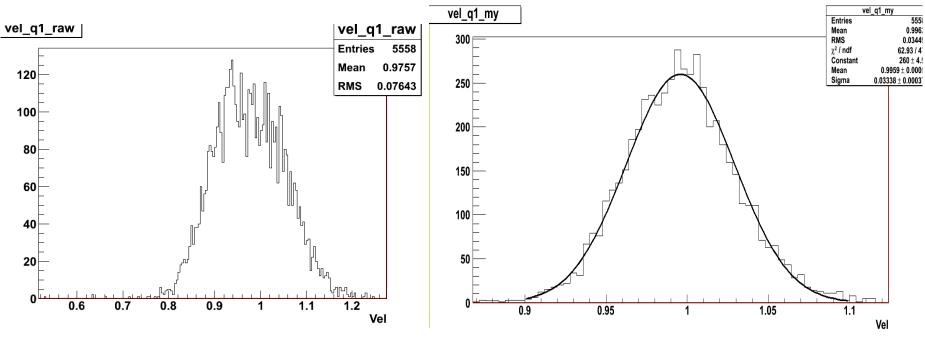
The Same Proton MIP ADC as ISS data



MC Proton Velocity Resolution

Rigidity=20GeV

Present LT=0.3-0.4 MIP



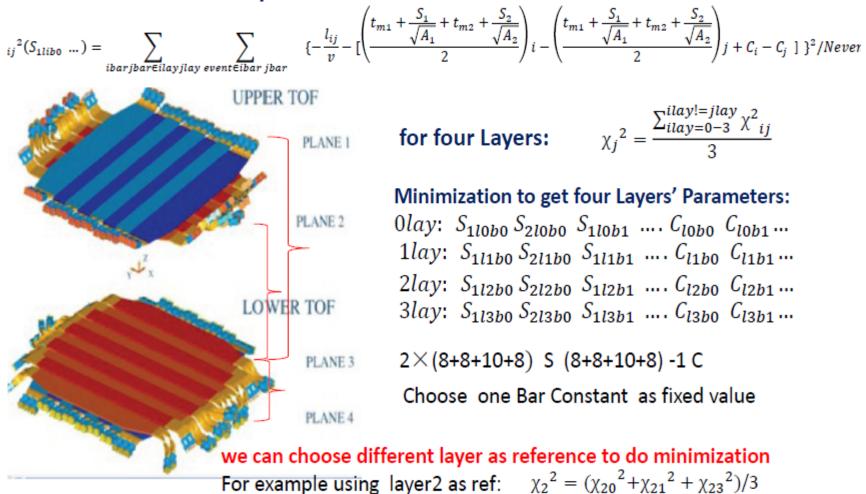
Before Slewing Calibration

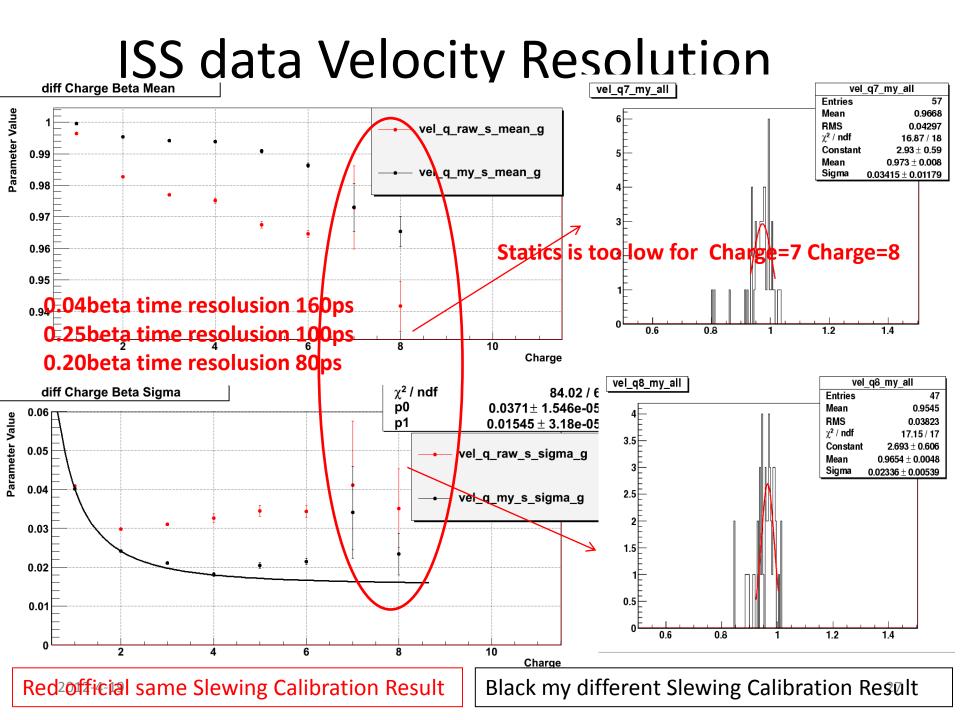
After Slewing calibration

Resolution is about 0.0334, much better than real data(0.04)

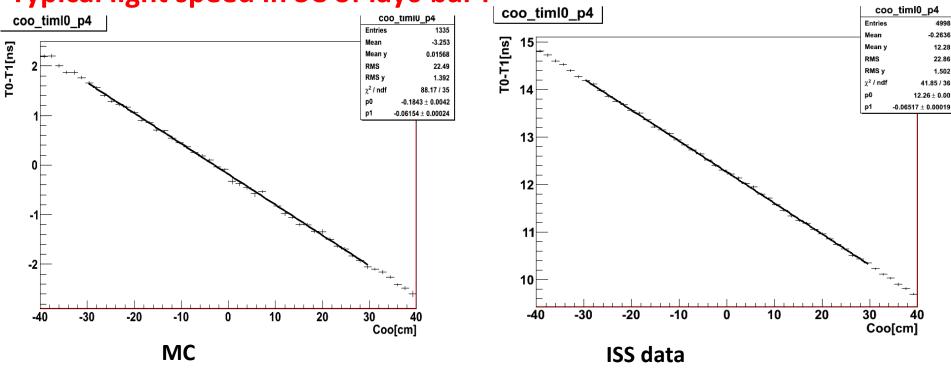
My Slewing Calibration

for two different fixed Layers:





Typical Velocity of photon in SC



Typical light speed in SC of lay0 bar4

MC is 1./0.06154=16.2cm/ns

ISS data is 1./0.06517=15.3cm/ns

!!! Old MC velocity=17.8cm/ns

Summary and to do list

1: New TOF Geant4 can simulate each photon transmit in TOF and reconstruction from detect photon both Geant4 part(material, geometry,process....) and electronics is ready(different PMT gain, PMT transmit time,SE...), code is ready for all. which successfully put and test in AMSsoft

2: Tuning Attenuation Length and photon number already done

3: MC MIP ADC tuning is also done. (SE-amp)

4: The resolution of MC Beta is a little better than Real data, need to tune

4: Time Calibration for MC should be better done by TOF Group. And also Charge and Coo calibration for MC.

7: AMSsoft TOF online simulation is slow(about 15-20s/event ---20GeV proton), Next have to get Fast simulation table with the help of TOF Geant4.

Tuning Introduction

TFMCFFKEY.seamref=1.; //(24)PMT single electron spectrum ref to 5mV TFMCFFKEY.seamres=0.9;//(25)PMT single electron spectrum resolution Rms/Mean TFMCFFKEY.selampec=0.2;//(26)PMT single electron low amplitude fraction TFMCFFKEY.selamref=0.2;//(27)PMT single electron low Amp/normal Amp TFMCFFKEY.pheffref=1.; //(28)photon ref eff uncertainty //absorption by gap(due to quality of polish)+glue(Sci-LG)+quantum effeciency uncertainty[0 4]

```
TFMCFFKEY.refmodel=1; //(29)(1)new polishbackpaint (2)polishbackpaint (3)groudbackpaint (4)unified dielectric_metal
TFMCFFKEY.absorp=0.; //(30)Sci-facet absorption prob[0,1]//MD-1
TFMCFFKEY.reflobsig=0.;//(31)Sci-facet lob-diffuse angle sigma//MD-1234
TFMCFFKEY.reflamber=0.; //(33)Sci-facet lob-diffuse reflection prob[0 1]//MD-1234
TFMCFFKEY.reflob=0.; //(33)Sci-facet lob-diffuse reflection prob[0 1]//MD-1234
TFMCFFKEY.refbac=0.; //(34)Sci-facet back-reflection prob[0 1]//MD-1234
TFMCFFKEY.refskin=1.; //(35)Al-skin reflection ref prob//small angle more possible reach Al surface//may affect final fast slow fraction [0 1./0.902]//MD-1234
TFMCFFKEY.refpolish=1.;//(36)Al-skin polish quality 1->Total mirror 0->diffuse//MD-1
```

```
TFMCFFKEY.birk=0.0116; //(37)scintillator Birks Constant de/dx/(1+a*de/dx) mm/MeV
TFMCFFKEY.phancut=0.1;// (38)cos(Angle 85deg) verticle direction photon cut
TFMCFFKEY.phtrlcut=5.;// (39)photon transmit track length cut //5m
TFMCFFKEY.phstepcut=2.;//(40)photon max steplength cut//2*m
//TFMCFFKEY.maxphcut=160000;//(41)max photon allow 0(inf) proton 20000ph*4cm*0.25(QE)
TFMCFFKEY.maxphcut=0;
//---
```

```
FFKEY("TFMC",(float*)&TFMCFFKEY,sizeof(TFMCFFKEY_DEF)/sizeof(integer),"MIXED");
```

MC Analysis class

```
class TofMCPmtHitR {
  public:
     int
            Idsoft; ///< Idsoft LBSP---L=Layer(0-3) B=Bar(0-9) S=Side(0-1) P=PMT(0-2)</pre>
     int
            ParId; //photon parent id
     float TimeG; //< time of photon in pmt (nsec)</pre>
     float TimeT; //< time of photon delay in SC+LG (nsec)
     float Ekin:
                    //< photon energy (eV)</pre>
     float Length; //< photon transmit length in SC+LG
     float Pos[3]; //< photon arrving pos
     float Dir[3]; //< photn arrving dir
     float TimeP; //transmit time in PMT
     float Amp;
                     //SE amp
     TofMCPmtHitR(){};
     TofMCPmtHitR(AMSTOFMCPmtHit *ptr);
     virtual ~TofMCPmtHitR(){};
  ClassDef(TofMCPmtHitR,1)
                                 //TofMCPmtHitR
  #pragma omp threadprivate(fgIsA)
203;
```